Claims:

- 1. A method for producing an aromatic compound isomer substituted with alkyl group(s) and/or halogen atom(s), through adsorptive separation by the use of a zeolite-containing adsorbent and a desorbent, wherein the desorbent is, after having been processed for removing impurities from it, supplied to the adsorptive separation step.
- 2. The method for producing an aromatic compound isomer as claimed in claim 1, wherein the aromatic compound has a benzene ring or heterocyclic ring structure.
- 3. The method for producing an aromatic compound isomer as claimed in claim 1 or 2, wherein the aromatic compound is ring-substituted with at least one halogen element.
- 4. The method for producing an aromatic compound isomer as claimed in any of claims 1 to 3, wherein the impurities in the desorbent are removed through any of distillation, purging or adsorption to a solid adsorbent.
- 5. The method for producing an aromatic compound isomer as claimed in any of claims 1 to 3, wherein the impurities in the desorbent are removed by replacing a part of the used desorbent with an impurity-free fresh desorbent.
 - 6. The method for producing an aromatic compound

isomer as claimed in any of claims 1 to 5, wherein all or part of the desorbent to be supplied to the adsorptive separation step is first continuously or intermittently supplied to a step of removing impurities from it, and then supplied to the adsorptive separation step.

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